	Туре	L#	Hits	Search Text	DBs	Time Stamp	Comm ents	Error Definitio n	Errors
1	BRS	L1	548	(CMP or ((chemical\$2 adj mechanical\$2) adj (polish\$3 or planariz\$5)) or polish\$3 or planariz\$5) same ((wash\$3 or rins\$3) with (ammonia or amine or ammine))	, ,	2007/03/31 15:33			
2	BRS	L2	314	1 and @pd<="20010830"		2007/03/31 15:34			
3	BRS	L3	156	(CMP or ((chemical\$2 adj mechanical\$2) adj (polish\$3 or planariz\$5)) or polish\$3 or planariz\$5) same ((wash\$3 or rins\$3) with (ammonia or amine or ammine) with (substrate or semiconductor or wafer))		2007/03/31 15:58			
4	BRS	L4	55	3 and @pd<="20010830"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2007/03/31 17:46			
5	BRS	L5	101	3 not 4	1 '	2007/03/31 15:47			
6	BRS	L6	0	(methylamine or ethanolamine or dimethylamine or methylethanolamine or "2-(methylamino)ethanol" or "aziridine" or "azetidine" or "pyrrolidine" or	EPO; JPO; DERWENT; IBM_TDB	2007/03/31 16:05			

	Туре	L#	Hits	Search Text	DBs	Time Stamp	Comm ents	Error Definitio n	Errors
7	BRS	L7	54	(CMP or ((chemical\$2 adj mechanical\$2) adj (polish\$3 or planariz\$5)) or polish\$3 or planariz\$5 or (post adj CMP)) and ((wash\$3 or rins\$3) with (methylamine or ethanolamine or amine or ammine or dimethylamine or methylethanolamine or "2-(methylamino)ethanol" or "aziridine" or "azetidine" or "pyrrolidine" or "piperidine" or "trimethylamine" or "dimethylethanolamine" or "2-(dimethylamino)ethanol" or analine) with (substrate or semiconductor or wafer))	USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2007/03/31 17:48	·		
8	BRS	L8	13	7 and @pd<="20010830"		2007/03/31 18:00			
9	BRS	L9	58	(CMP or ((chemical\$2 adj mechanical\$2) adj (polish\$3 or planariz\$5)) or polish\$3 or planariz\$5 or (post adj CMP)) and ((wash\$3 or rins\$3) with (methylamine or ethanolamine or amine or ammine or dimethylamine or methylethanolamine or "2-(methylamino)ethanol" or "aziridine" or "azetidine" or "pyrrolidine" or "piperidine" or "trimethylamine" or "c" (dimethylamino)ethanol" or analine or hydroxylamine or hydrazine) with (substrate or semiconductor or wafer))	US-PGPUB; USPAT; USOCR; EPO; JPO;	2007/03/31 17:57		·	
10	BRS	L10	17			2007/03/31 17:50			
11	BRS	L11	1358	planariz\$5)) or polish\$3 or planariz\$5 or (post adj CMP)) and ((wash\$3 or rins\$3) with (solvent or organic) with (substrate		2007/03/31 18:26			

	Туре	L#	Hits	Search Text	DBs	Time Stamp	Comm ents	Error Definitio n	Errors
12	BRS	L12	475		US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2007/03/31 18:02			
13	BRS	L13	95	12 and "438"/\$.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2007/03/31 18:27			
14	BRS	L14	25	12 and "451"/\$.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2007/03/31 19:49			
15	BRS	L15	126	MAY-CHARLES-E.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2007/03/31			